



Plasma Combustion and Flow Control Processes

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Message from the Guest Editors

This Special Issue on “Plasma Combustion and Flow Control Processes” seeks high-quality works, focusing on the latest plasma technologies for plasma-assisted combustion, enhanced ignition, and flow control. Topics include but are not limited to:

1. Application of plasma in the combustion of new fuels;
2. Mechanism of plasma-assisted combustion and enhanced ignition;
3. Plasma flow control processes, including research on the boundary layer, vortex, shock wave, ion wind, flow illustration, etc.;
4. Diagnostic methods related to plasma combustion and flow control.

Deadline for manuscript submissions:

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Message from the Editor-in-Chief

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